

CORRECTION

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Correction: Inkjet assisted fabrication of planar biocompatible memristors

Georgii A. Illarionov,^a Denis S. Kolchanov,^a Ivan Mukhin,^{ab} Oleg A. Kuchur,^a
 Mikhail V. Zhukov,^{ac} Ekaterina Sergeeva,^a Vladimir V. Krishtop,^{ad}
 Alexandr V. Vinogradov^a and Maxim I. Morozov^{*a}

Correction for 'Inkjet assisted fabrication of planar biocompatible memristors' by Georgii A. Illarionov *et al.*, *RSC Adv.*, 2019, 9, 35998–36004.

The authors regret that one of the co-authors, Ivan Mukhin, was omitted from the original article. The correct author list is as shown here.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

^aLaboratory of Solution Chemistry of Advanced Materials and Technologies, ITMO University, Lomonosova str. 9, St. Petersburg, 191002, Russia. E-mail: maximm@alumni.ntnu.no; morozov@scamt-itmo.ru

^bSt. Petersburg Academic University, Khlopina 8/3, St. Petersburg, Russia

^cInstitute for Analytical Instrumentation RAS, Ivan Chernykh str. 31-33, St. Petersburg, 198095, Russia

^dResearch Center, Ivanovo State Medical Academy, Sheremetevsky ave. 8, Ivanovo, 153012, Russia

